Interaction: atomic approach (IR to vis/UV)



Interaction: atomic approach (UV to X-rays)



Cross section

- A single atom in the origin
- Interaction produces dN particles per unit time in the solid angle $d\Omega$

$$dN = \Phi_0 d\sigma = \Phi_0 \left(\frac{d\sigma}{d\Omega}\right) d\Omega$$
$$\sigma = \int_{4\pi} \left(\frac{d\sigma}{d\Omega}\right) d\Omega$$

 $[\sigma] = cm^2$ 1 barn = 10⁻²⁴ cm²

Ge, Z = 32, $\hbar \omega$ =10 keV $\sigma_{\rm photo}$ = 4 × 10³ barn $\sigma_{\rm el}$ = 2 × 10² barn $\sigma_{\rm inel}$ = 1 × 10¹ barn



$$d\Omega = \\ d\theta \\ \sin \theta \ d\theta \ d\phi \\ \theta \\ r \\ \phi \\ d\phi \\ d\phi \\ \Phi_0$$

Impinging beam of monochromatic photons, flux Φ_0 Φ_0 =photons/(s cm²)

Cross section & linear attenuation coefficient



A homogeneous sample composed by identical atoms with density ρ (atoms/cm³)

- Single scattering

 approximation: the
 number of particles
 created by the interaction
 is ∝ number of atoms
 involved
- The number of particles created by a slab of thickness dx at position x in the full solid angle is

 $dN = \Phi \sigma dn$ $= \Phi \sigma \rho A dx$ $= I \sigma \rho dx$



Cross section & linear attenuation coefficient



A homogeneous sample composed by identical atoms with density ρ

- $dN = I \sigma \rho dx$
- Single particle approximation: an impinging photon can create only one particle. Therefore

$$dN = -dI$$
$$dI = -I \ \sigma \rho \ dx$$

 This is the same relation which defines the linear attenuation coefficient, thus

$$\mu = \sigma \rho$$



Cross section & linear attenuation coefficient



• If the sample is composed of different atoms with densities ρ_i and cross sections σ_i then

$$\mu = \sum_{i} \rho_i \sigma_i$$

Cross sections are also expressed as mass attenuation coefficients, expressed as cm²/g, so that

 $\mu(cm^{-1}) = \rho(g/cm^3) \sigma(cm^2/g)$



Cross section of various processes



Elastic scattering from 1 free electron (Thomson)

- Thomson scattering = coherent scattering
- The scattered electric field is (linear polarization case)

$$E(\vec{r},t) = -E_0 r_0 \left(\frac{e^{i(kr-\omega t)}}{r}\right) \sin \theta$$

$$r_0 = \frac{e^2}{4\pi\varepsilon_0 mc^2} \cong 2.82 \times 10^{-15} \text{m} \qquad \text{Angle be}$$

"Thomson scattering length" or "classical electron radius" Angle between the polarization vector and the scattered wave vector R S

The exchanged wave vector

•
$$\vec{q} = \vec{k}' - \vec{k}$$

• For elastic scattering $\left|\vec{k}'\right| = \left|\vec{k}\right| = k$ and

$$q = \frac{4\pi}{\lambda} \sin \theta$$





Elastic scattering from 1 free electron (Thomson)

• The differential cross section is

 $\frac{d\sigma}{d\Omega} = r_0^2 (\hat{\varepsilon} \cdot \hat{\varepsilon}')^2$

Polarization vectors of the incident and scattered waves



Elastic scattering from 1 free electron (Thomson)

• The angle integrated (total) cross section is

$$\sigma = \frac{8\pi}{3}r_0^2$$

• NB: it is independent of energy



Elastic scattering from one atom

• For one atom

$$E(\vec{r},t) = -E_0 r_0 \left(\frac{e^{i(kr-\omega t)}}{r}\right) f(Z,\theta) \sin \theta$$

• $f(Z, \theta)$ is the «atomic form factor» or «scattering amplitude»; no physical dimensions



Elastic scattering from one atom

• The differential cross section $\frac{d\sigma}{d\Omega} = \frac{d\sigma_{electron}}{d\Omega} |f(Z,\theta)|^2$

- *f* depends quasi linearly on *Z*
- $f(\theta = 0) = Z$



Inelastic scattering

 The most common inelastic scattering mechanism for X-rays is the Compon effect (= "incoherent scattering")

$$\Delta \lambda = 2\pi \lambda_c (1 - \cos \theta),$$

$$\lambda_c = \frac{\hbar}{mc} \cong 3.86 \times 10^{-13} \text{m},$$
Reduced Compton
wavelength

$$a_0 = \frac{4\pi\varepsilon_0 \hbar^2}{me^2} \cong 0.53 \text{\AA}$$

$$\alpha = \frac{e^2}{4\pi\varepsilon_0 \hbar c} \cong \frac{1}{137}$$
Radius of the Bohr 1st
orbit for H

$$\lambda_c = \left(\frac{e^2}{4\pi\varepsilon_0 \hbar c}\right) \left(\frac{4\pi\varepsilon_0 \hbar^2}{me^2}\right) = \alpha a_0$$
Fine structure constant

$$r_0 = \left(\frac{e^2}{4\pi\varepsilon_0 \hbar c}\right) \left(\frac{\hbar}{mc}\right) = \alpha \lambda_c = \alpha^2 a_0.$$

Compton cross section

• The Klein Nishina formula

$$\frac{d\sigma}{d\Omega} = r_0^2 \left(\frac{\omega'}{\omega}\right) \left|\hat{\varepsilon} \cdot \hat{\varepsilon}' + \frac{(\omega' - \omega)}{4\omega'\omega}\right|^2$$



Thomson and Compton scattering



Elastic and inelastic scattering differential cross section for different elements as a function of the incident photon energy for a fixed scattering angle equal to 90 degrees. (Calculated using the data from reference

Photoelectric absorption

- A photon is absorbed and gives its energy to an electron.
- The electron makes a transition to
 - \circ A bound state (excitation)
 - <u>or</u>
 - An unbound state
 (ionization): a
 photoelectron is created



Energetics of photoelectric absorption in an atom (ionization)



Photoelectric absorption in solids

- In solids valence electrons form <u>bands</u>
 - Insulators and semiconductors: valence and conduction bands
 metals: conduction band
- The «vacuum level» is the least energy an electron can have to leave the solid (with K.E. = 0)

 $\,\circ\,$ Often taken as reference level

 At sufficiently high energies the photoelectron can be considered «free»: it has only kinetic energy





Conservation of energy

 In the one electron approximation for a transition from a core level:

Initial state energy = $\hbar\omega + E_C$ ($E_C < 0$) Final state energy = K $K = \hbar\omega + E_C$

$$E_C = -E_B$$
 (binding genergy)
 $K = \hbar \omega - E_B$





Absorption coefficient: energy dependence



Z dependence of absorption edges



Energy of photoelectric absorption edges versus atomic number of the elements.

The atomic number determines the energy of the absorption edge

 The observation of an edge at a given energy indicates the presence of the
 corresponding

element

Photoelectric absorption: de-excitation



"fluorescence" X-rays, also known as "emission lines" $\hbar \omega_f = E_L - E_K$



Probability for the two processes





Nomenclature for X-ray emission lines



Energy of emission lines

TABLE B.2.	Photon energies, in electron volts, of principal K and L shell emission l							Energy depends on Z		
Element	Κα1	Ka2	Кβ1	La ₁	L ₂	$L\beta_1$				
3 Li	54.3						•	Massurament of the		
4 Be	108.5							Measurement of the		
5 B	183.3							onorgy and intensity		
6 C	277							energy and intensity		
7 N	392.4									
8 O	524.9							of v ray omission		
9 F	676.8	12.727427								
10 Ne	848.6	848.6								
11 Na	1,040.98	1,040.98	1,071.1					lines is at the basis of		
12 Mg	1,253.60	1,253.60	1,302.2							
13 Al	1,486.70	1,486.27	1,557.45							
14 Si	1,739.98	1,739.38	1,835.94					many "analytical"		
15 P	2,013.7	2,012.7	2,139.1					many analytical		
16 S	2,307.84	2,306.64	2,464.04					techniques which		
17 Cl	2,622.39	2,620.78	2,815.6					LECHINGUES WINCH		
18 Ar	2,957.70	2,955.63	3,190.5							
19 K	3,313.8	3,311.1	3,589.6					mascura tha		
20 Ca	3,691.68	3,688.09	4,012.7	341.3	341.3	344.9		illeasure the		
21 Sc	4,090.6	4,086.1	4,460.5	395.4	395.4	399.6				
22 Ti	4,510.84	4,504.86	4,931.81	452.2	452.2	458.4		presence and		
23 V	4,952.20	4,944.64	5,427.29	511.3	511.3	519.2				
24 Cr	5,414.72	5,405.509	5,946.71	572.8	572.8	582.8		as a solution of	C	
25 Mn	5,898.75	5,887.65	6,490.45	637.4	637.4	648.8		concentration of KER	3	
26 Fe	6,403.84	6,390.84	7,057.98	705.0	705.0	718.5			V	
27 Co	6,930.32	6,915.30	7,649.43	776.2	776.2	791.4		elements in a sample		
28 Ni	7,478.15	7,460.89	8,264.66	851.5	851.5	868.8			1 100	
29 Cu	8,047.78	8,027.83	8,905.29	929.7	929.7	949.8			A	
30 Zn	8,638.86	8,615.78	9,572.0	1,011.7	1,011.7	1,034.7			20	

Auger electrons



- Nomenclature

 (Hole)(1st e⁻)(2nd e⁻)
- The energy depends on Z
- Measurement of the energy and intensity of Auger electrons = "Auger Electron Spectroscopy", an analytic technique which measures the presence and concentration of elements on the surface of a sample

Relationship between two approaches

- Two approaches to describe the interaction between x-rays and matter
 - «Macroscopic»: by means of the dielectric function which describes the overall response
 - «Microscopic»: by means of interactions between photons and atoms
- What is the relation between these approaches?
- It is possible to derive a simple relation between the index of refraction and the atomic form factor

Relation between n and f

- For a sample composed of identical atoms with form factor f and density ρ

$$n(\omega) - 1 = -\frac{2\pi r_0 \rho f(\omega, q = 0)}{k^2}$$

- $n(\omega)$ has a real and immaginary part: also $f(\omega)!$
 - Real part: dispersion
 - Immaginary part: attenuation



«Anomalous" corrections to the form factor

- It is common to separate the dependence on \vec{q} and ω : $f(\vec{q}, \omega) = f^0(\vec{q}) + f'(\omega) - if''(\omega)$
 - $\succ f^0(\vec{q})$: atomic scattering far from resonance frequencies / absorption edges
 - F'(ω): correction to dispersive part, important near resonance frequencies
 - $\succ f''(\omega)$: correction to attenuation part, important near resonance frequencies



The total cross section

• The total cross section determines the attenuation, $\sigma_T(\omega) = \frac{\mu(\omega)}{\rho} = \frac{2\omega n_2(\omega)}{c\rho}$

• Since
$$n_2(\omega) = \frac{2\pi r_0 \rho f''(\omega, q=0)}{k^2}$$

$$\sigma_T(\omega) = \frac{4\pi r_0}{k} f''(\omega, q = 0)$$

one form of the «optical theorem», which links the total cross section to the imaginary part of the forward scattering amplitude